

Source: [Effect of Discrete Levels Width Error on the Optical Performance of the Diffractive Binary Lens](#) by Manal Alshami, Mohamed Fawaz Mousselly, and Anas Wabby, used under [CC-BY](#)

Effects of Discrete Levels Width Errors of discrete levels on the Optical Performance of binary the Diffractive Binary Lens

AUTHOR ONE,¹ AUTHOR TWO,^{2,*} AND AUTHOR THREE^{2,3}

¹Peer Review, Publications Department, The Optical Society, 2010 Massachusetts Avenue NW, Washington, DC 20036, USA

²Publications Department, The Optical Society, 2010 Massachusetts Avenue NW, Washington, DC 20036, USA

³Currently with the Department of Electronic Journals, The Optical Society, 2010 Massachusetts Avenue NW, Washington, DC 20036, USA

*xyz@osa.org

Abstract: The effects of [width errors of](#) discrete levels ~~width error developed by during~~ thin-film deposition on the optical performance of [a binary](#) diffractive ~~binary~~-germanium lens ~~with four discrete levels~~ are investigated using [the nonsequential mode](#) ~~and four discrete levels~~ in the optical design code ZEMAX. The thin-film deposition ~~technique~~ errors considered are ~~all~~ metallic mask fabrication errors. The peak value of the ~~Ppoint Sspread Ffunction~~ (PSF) ~~was is~~ used as [the](#) criterion to show the effects of [the width errors of the four](#) discrete levels ~~width error~~ on the optical performance of the ~~four level~~-binary germanium lens.

© 2020 Optical Society of America under the terms of the [OSA Open Access Publishing Agreement](#)

1. Introduction

~~To enhance optical resolution and reduce aberrations,~~ Refractive and diffractive lenses are often combined ~~as into~~ a hybrid lens [to enhance optical resolution and reduce aberrations](#) [1]. Diffractive lenses are ~~essentially primarily~~ gratings with variable groove spacings across the optical surface, which ~~impart cause a~~ changes in [the](#) phases of ~~the~~ wavefronts passing through ~~it them~~ [2].

A diffractive optical element (DOE), with [a](#) continuous surface profile, is often referred to as [a](#) kinoform, and the ~~ideal~~ theoretical ~~ideal~~ profile of the diffractive surface can be ~~discretely~~ approximated ~~in a discrete fashion~~ (the sag is approximated ~~by in~~ discrete steps), ~~in a manner~~ similar to the digital representation of an analog function [3]. This discrete representation is called a multilevel or binary profile [4]. The design techniques used ~~in for~~ binary optics were initially developed by integrated circuit ~~(IC)~~ manufacturers, ~~by by~~ using ~~the computer-aided design CAD~~ software [4].

Diffractive surfaces in most ~~of the~~ optical design codes, such as Oslo [5] and ZEMAX [2], are closer approximations to kinoforms than true binary optics, since the phases ~~is are~~ continuous everywhere, ~~so hence~~ the ~~evaluation of the~~ optical performance ~~evaluations of that~~ such elements ~~are often will be done considered~~ for continuous phase profile cases [6].

Swanson [3] ~~has developed a technique using used the~~ Optical Research Associates' (ORA's) Code V lens design software [7] to ~~develop a technique for designing DOEs diffractive optical elements~~. This ~~is was~~ possible because the code used ~~s~~ direct ray tracing with a subcode for ~~the~~ holographic optical elements (HOEs), which ~~can be used to allows~~ partially simulation ~~e~~ of the binary elements. The finite-difference time-domain method ~~was has also been~~ used to simulate subwavelength diffractive lenses [8, 9]. ~~But, for Some a few of the~~ optical designers ~~prefer who using~~ the optical design code ZEMAX, ~~it will be preferable~~ to design [the binary](#)

Commented [A1]: Dear author, Thanks for providing this opportunity to assist you with this manuscript. I have edited the text for language, grammar, and improved clarity. I have also checked the manuscript for conformance with the formatting guidelines of the *Journal of the Optical Society of America A*, as instructed. There are a few instances where additional information is required from you, and I have added comments to bring them to your attention. Should you have any concerns, please feel free to get back to me. In case you make any revisions to this manuscript, please get them checked by us before you submit to the journal. This will ensure that the manuscript does not receive negative comments on language. You can use our multiple round service to get your paper rechecked by us. My best wishes for your success with the manuscript.

Commented [A2]: The title has been modified for clarity and readability.

Commented [A3]: This is the more commonly used version of this term; hence, I have made this change throughout this manuscript.

Commented [A4]: This is from the template file. Please include the author names, affiliations, and corresponding author contact information in the format shown here.

Commented [A5]: The current abstract is within the 100 words length limit suggested by the journal template.

Commented [A6]: Capitalization is generally reserved for proper nouns and need not be used in such instances.

Commented [A7]: As this abbreviation is not used in the abstract, I have removed it.

Commented [A8]: This abbreviation is not used anywhere in this manuscript, so I have removed it. I have made similar changes to some other terms that are not used as well.

Formatted: Font: (Default) Times New Roman, 10 pt

Commented [A9]: I have split this sentence into two to avoid lengthy sentence constructions. Further, please explain what you mean by "everywhere" because the meaning is slightly unclear in this context.

Formatted: Font: (Default) Times New Roman, 10 pt

diffraction binary lens by it, but However, the optical design code ZEMAX does not allow the direct modeling of the wavelength-scale grooves directly. Instead, ZEMAX it uses the phase advance or delay represented by the local surface locally to change the direction of propagation of the ray [2].

The fabrication of the single-level and multilevel diffractive lenses involves the generation of a set of masks that are used sequentially for the to transfer of their patterns to a substrate sequentially in conjunction with photoresist deposition, exposure, and development, as well as an etching procedure, such as reactive-ion etching [10], or with thin-film deposition [11, 12].

For example, K masks are needed for a lens with of 2^K phase levels [3]. The development of these masks (photoresist [11] or metallic [12]) is generally not usually error-free. These such errors are usually known as mask fabrication errors and cause significant deformations of in the resulting binary diffractive binary lens surface and corresponding deterioration of the lens performance. Therefore, the analysis of the effects of these errors on the performance of diffractive optical elements DOE performances and the determination of acceptable fabrication tolerances for each design is are of central importance.

Choi et al. had used geometrical and Fourier optics theory to simulate the decrease in of the modulation transfer function MTF due to diffractive optical element DOE fabrication errors [1]; Glytsis et al. and others [10] had used the b Boundary-Element M method (BEM) as the basic modeling tool for to analyzing diffractive lenses with fabrication errors. The effects of fabrication errors on the predicted performances of surface-relief phase gratings are were analyzed by Pommet et al. with using a rigorous vector diffraction technique by Pommet et al. [13]. Jabbar had used the method of generalized projection method to study the effects of experimental errors on the diffractive optical element DOE performance [14].

Alshami et al. [12] had used metallic masks in the to development of a binary diffractive germanium lens by thin-film deposition, hopefully, this The present paper study shows the effects of discrete levels-width errors of discrete levels due to metallic mask fabrication errors on the optical performance using nonsequential mode in ZEMAX to design the of a four-level binary surface of a diffractive germanium lens designed using the nonsequential mode in ZEMAX. In the following sections, where the first part presents the design of the 4 four-level step binary surface of a binary diffractive germanium lens [12] with nonsequential mode in ZEMAX is presented first, and the second part presents the effects of the discrete levels width errors of discrete levels due to the mask fabrication on the optical performance are described thereafter using the peak value of the point spread function (PSF) as a criterion.

2. Design of F four-Step level B binary S surface in ZEMAX

The design of a four-level step binary surface of the a binary diffractive binary germanium lens [12] by using the nonsequential mode in ZEMAX will be is presented via in the following subsections procedure.

2.1 Refractive L lens

Table 1 lists shows the optical design specifications of the refractive germanium (planoconvex) lens; as shown illustrated in Fig ure 1; for at the wavelength band of (8) (12) μ m, an effective focal length of 75 mm with a 9.09 degree field of view, and a diameter of 33 mm.

Table 1. Specifications of the rRefractive L lens (mm).

Surface	Type	Radius	Thickness	Glass	Diameter
OBJ	Standard	Infinity	Infinity		0.000
STO	Standard	225.371	5.000	Germanium	33.097
2	Standard	Infinity	72.849		32.787
IMA	Standard	Infinity			13.435

Commented [A10]: This is the more common style of representing such reference mentions.

Formatted: Font: (Default) Times New Roman, 10 pt

Commented [A11]: A "paper" is only a written summary of your work and does not adequately represent all the procedures that constitute your efforts. Hence, it is more appropriate to use "study" or "work" in such instances.

Formatted: Font: (Default) Times New Roman, 10 pt

Commented [A12]: I have split this sentence into two to avoid a lengthy sentence.

Formatted: Font: (Default) Times New Roman, 10 pt

Formatted: Font: (Default) Times New Roman

Commented [A13]: Note that this table contains abbreviations that are not defined previously. Please consider mentioning the full forms in a footnote to this table. I have moved this table from the previous section to this point, since the journal instructions recommend placing tables as closely as possible to where they are mentioned in the text. I have also done this for other tables and figures as necessary. Please note that these rearrangements were made with Track Changes off, so the edits made to the text in the tables and figures are easily visible.

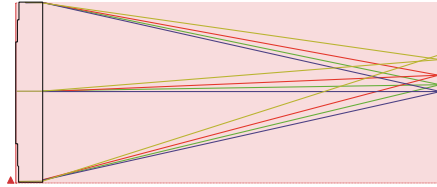


Fig.ure 1: Layout of the refractive lens.

Commented [A14]: No changes are required to this figure.

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Times New Roman, 8 pt

2.2 Diffractive Lens

Table 2 lists shows the optical design specifications of the diffractive germanium lens, with the same specifications conditions as the refractive lens one, and with the plane surface chosen as the binary 2 surface (1), as shown in Fig.ure 2:

$$\phi = -0.65554\rho^2 + 8.97589\rho^4. \quad (1)$$

Table 2: Specifications of the diffractive lens (mm):

Surface	Type	Radius	Thickness	Glass	Diameter	Coeff. on ρ^2	Coeff. on ρ^4
OBJ	Standard	Infinity	Infinity		0.000		
STO	Standard	225.371	5.000	Germanium	33.097		
2	Binary 2	Infinity	73.339		32.787	-0.65554	8.97588
IMA	Standard	Infinity			13.323		

Commented [A15]: Please define this variable.

Formatted: Right

Commented [A16]: Please include a footnote for this table as well.
Please note that Tables 2 and 3 were originally created as a single table. I have split these into two, since each table needs to stand independently. This was also the case with Tables 4 and 5.

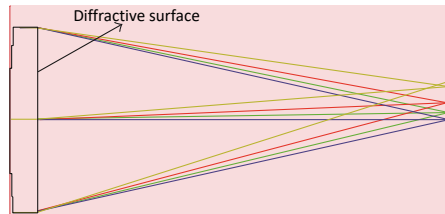


Fig.ure 2: Layout of the diffractive lens.

Commented [A17]: No changes are required to this figure.

2.3 Switching from Kinoform to Binary Surface

In the optical design of the considered-proposed lens [12], the diffractive surface contained one diffractive zone, and the ideal diffractive phase profile to be approximated in a binary fashion manner (4-four steps or 4-phase levels) is given by (1). The diameters of the each discrete phase levels or binary steps (equivalent to phase values $\pi/2, \pi, 3\pi/2$, and 2π) and the sag's thicknesses equivalent to the each phase values are provided shown in Table 3 and Fig.ure 3 [12].

Table 3: Diameters and Thickness of each binary zone

Binary zone's number	Equivalent phase value	Radius of each binary zone (mm)	Diameter of each binary zone	
	Equivalent sag's thickness (radian)		(mm)	(μm)
1	$\pi/2$	11.148	22.295	0.833
2	π	13.089	26.177	1.667
3	$3\pi/2$	14.404	28.807	2.498

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Cambria Math

Commented [A18]: The last column on the right side appears to be a different parameter than the diameter of the binary zone. Please check and revise if needed.

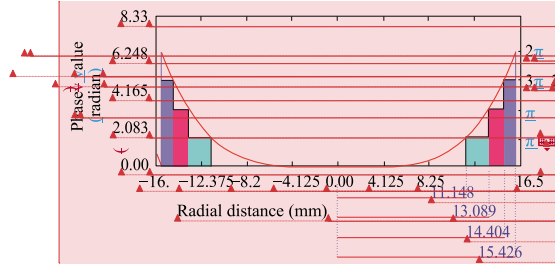


Figure 3: Phase curve versus aperture of the diffractive surface sliced into 2π layers and the discrete phase levels.

2.4 Design of Four-Steplevel Binary Surface of a binary Diffractive Germanium Lens

The design of the four-layerstep binary surface of the binary diffractive germanium lens by using the nonsequential mode in ZEMAX is presented in Tables 4 and 5, and it was done by using the object cylinder volume, which is a rotationally symmetric volume, was used to design each step of the germanium material, wherein the diameters of the front and rear faces of each cylinder are the same as their equivalent binary steps, and the length along the local z-axis of each cylinder is the thickness of the equivalent binary step, as shown in Figure 4. For the optical design in the nonsequential mode, we need to define the x, y, and z positions of each object.

Table 4: Optical Design of the Binary Germanium Lens in a Nonsequential Mode.

Surface	Type	Radius	Thickness	Glass	Diameter	Exit lock Z
OBJ	Standard	Infinity	Infinity		Infinity	
STO	Standard	225.371	5.000	Germanium	33.097	
2	Standard	Infinity	0.000		32.787	
3	Nonsequential	Infinity			32.787	73.368
IMA	Standard	Infinity			13.342	

Table 5: Data in the Nonsequential Component Editor

Object number	Object 1	Object 2	Object 3	Object 4	Object 5	Object 6
Object type	Standard lens	Cylinder volume	Standard lens	Cylinder volume	Standard lens	Cylinder volume
Z position (mm)	0.000	0.000	0.000833	0.000833	0.001667	0.001667
Material	Germanium		Germanium		Germanium	
Front R (mm)	0.000	11.148	0.000	13.089	0.000	14.404
Z length (mm)	0.000	0.000833	0.000	0.000833	0.000	0.000833
Back R (mm)	16.500	11.148	16.500	13.089	16.500	14.404

Commented [A19]: The symbols were missing along the right-side axis. Please check if the corrections are accurate.

Formatted

Formatted

Formatted

Formatted

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted

Formatted

Formatted

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Formatted: Font: (Default) Times New Roman, 8 pt

Formatted

Commented [A20]: Please include the table footnote and mention the units for the numerical data in the caption.

Edge 1 (mm)	16.500	Not used	16.500	not used	16.500	Not used
Thickness (mm)	0.000833	Not used	0.000833	not used	0.000833	Not used
Clear 2 (mm)	16.500	Not used	16.500	not used	16.500	Not used
Edge 2 (mm)	16.500	Not used	16.500	not used	16.500	Not used

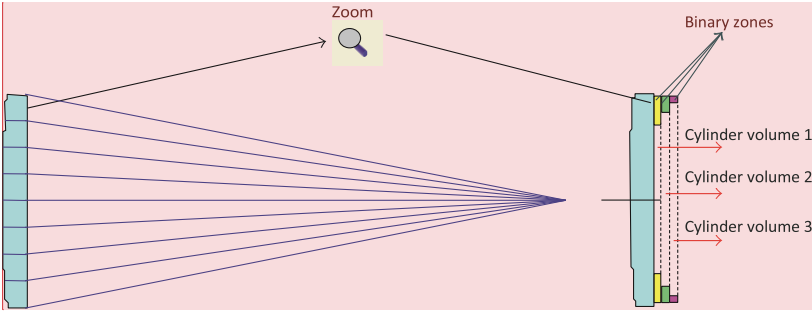
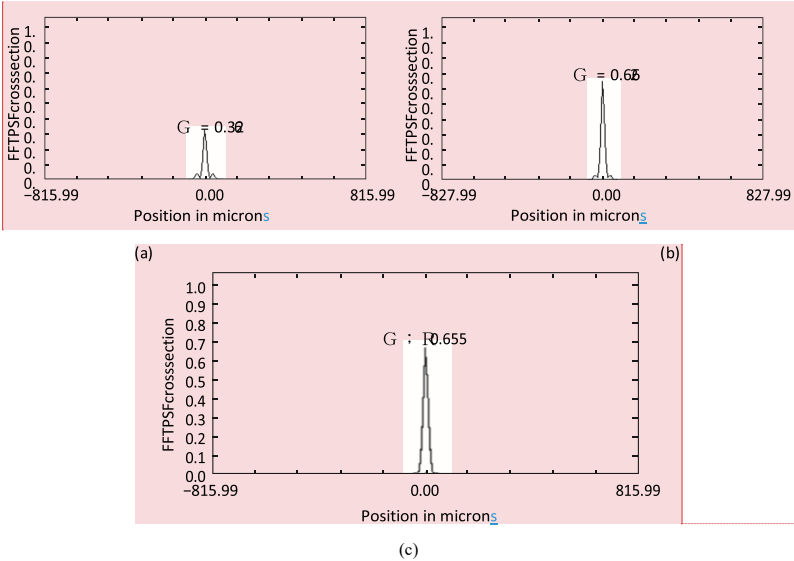


Figure 4: The binary diffractive lens with discrete phase levels.

Figure 5 shows the differences in the fast Fourier transform (FFT) PSF cross-sectional curves between among the refractive, diffractive, and the designed four-level step binary germanium lens.



Commented [A21]: No changes are required to this figure.

Formatted: Font: Times New Roman, 10 pt

Formatted: Font: Times New Roman, 10 pt

Formatted: Font: Times New Roman, 10 pt

Formatted: Font: Times New Roman, 10 pt

Formatted: Font: Times New Roman, 10 pt

Commented [A22]: The numbers along the axes and within the figures seem to have been cut off by placement of the figure in the template. Please check and provide static (non-editable) images in your final draft to prevent unintentional changes to the figures.

Figure 5: FFT PSF cross sections of (a) refractive lens, (b) diffractive lens, and (c) designed binary lenses.

3. Effects of width errors of discrete levels on performance of DOE

Imprecisions in the metallic mask fabrication process can cause the widths of the discrete levels to differ from their theoretical target values; consequently, this can have an adverse effect on the optical performance. To understand how this effect degrades performance and thus to obtain the tolerances for fabrication errors, we studied how the changes in the peak values of the PSFs of the designed lens change as a function of the discrete levels or zone width variations. The variable Δw was introduced to specify the differences between the final and intended positions of the boundaries of each binary zone (an expected error is obtained for the width of each binary zone will result due to the metallic mask fabrication accuracy of 0.1 mm of the laser machine), as shown in Figure 6 [12]; the width of each binary zone was then changed by $2\Delta w$ ($2\Delta w = 0.2$ mm). The sign of Δw can be either positive or negative, corresponding to wider and/or narrower zones, respectively. In this study, it was assumed that Δw was equal for all zones and independent of their widths.

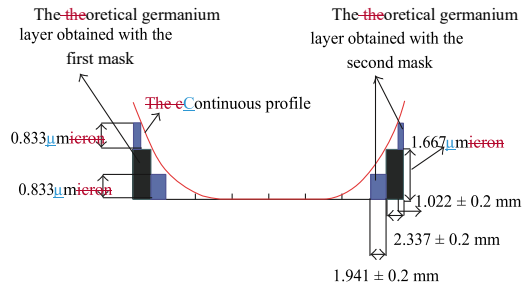


Figure 6: Germanium layers (binary zones) and the expected errors in their widths.

4. Results and Discussion

Table 6 and Figure 7 show the variations in peak values of the PSFs as a function of $2\Delta w$. The observed changes in $2\Delta w$ studied were limited to 200 μm ($\Delta w = 100$ μm , i.e., the metallic mask fabrication error caused by of the laser machine). A change of 200 μm for $2\Delta w$ has the effect of lowering the PSF peak value (Table 6) by 5%, thus lowering the diffraction efficiency by 5% [15].

Figure 8 shows the FFT PSF cross section of the considered lens for the extreme error values and without any errors. It can be seen from the figure that, for this proposed particular binary diffractive lens, the axial resolution increases with increasing zone widths, but this occurs at the expense of results in decreasing the PSF peak values. The metallic mask can be replaced with masks of similar dimensions which can be produced by using three-dimensional printers (rapid prototype) with an accuracy of 35 μm so such that the width errors of the discrete levels width error will change from -70 μm to 70 μm , which cause lowering in PSF peak value less than 2% then lowering in diffraction efficiency less than 2%; in this case, within the 70 μm change in $2\Delta w$, the performance of the considered lens is still acceptable.

Table 6: Peak values of the PSFs as a function of $2\Delta w$.

$2\Delta w$ (μm)	-200	-150	-100	-50	0.00	50	100	150	200
Peak value of PSF	0.667	0.6684	0.6681	0.662	0.655	0.648	0.642	0.634	0.626

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Times New Roman

Formatted: Font: (Default) Cambria Math

Formatted: Font: (Default) Times New Roman

Commented [A23]: All necessary changes have been incorporated in the figure.

Commented [A24]: The original sentence is somewhat lengthy and cannot be split without repetition, so I have tried to retain it as is; please check that your intended meaning is retained

Formatted: Font: (Default) Times New Roman, 10 pt

Commented [A25]: I am not certain of your intended meaning here. Please clarify what you wish to convey so that I can provide suitable revisions.

Formatted: Font: (Default) Times New Roman, 10 pt

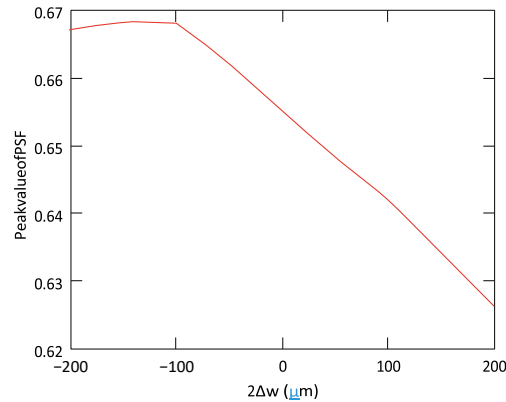


Fig. ure 7: Peak value of PSF as a function of variation in zone width error.

Commented [A26]: Please include a space between each word in the y-axis label.

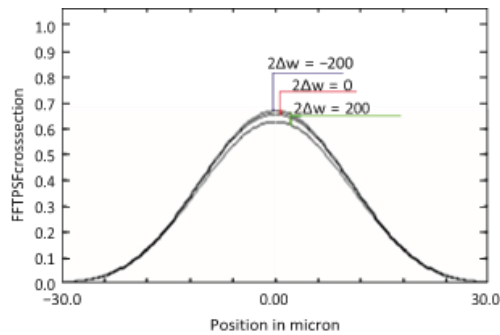


Fig. ure 8: FFT PSF cross section.

Commented [A27]: Please note that the labelling on the x-axis should be "Position in microns". Please include a space between each word in the y-axis label.

5. Conclusion

The effects of width errors of discrete levels ~~width error developed fabricated~~ by thin-film deposition on the optical performance of a four-level binary diffractive ~~binary~~ germanium lens ~~with four discrete levels have been were~~ analyzed using the nonsequential mode in the optical design code ZEMAX. The ~~primary errors in the thin-film deposition technique errors~~ considered ~~in this study were~~ are metallic mask fabrication errors. ~~It was found by using the~~ The peak values of the PSFs ~~as criterion that of~~ the metallic mask fabrication errors (100 μm laser machine accuracy of 100 μm) were found to have a significant considerable effects on the performance of the designed four-level binary germanium lens performance, and ~~to~~ to reduce this such effects, it ~~will may~~ be preferable to use masks fabricated by alternative another techniques ~~to fabricate the desired mask, such as 3D printing, which with allow more better fabrication accuracy like, for example, by three dimensional printer (~35 μm is its accuracy).~~

Formatted: Font: (Default) Times New Roman

Competing ~~4~~ interests. The authors declare that they have no competing interests.

Acknowledgments. This work was ~~totally fully~~ supported by HIAST ~~(the~~ Higher Institute for Applied Sciences and Technology (HIAST).

References

1. H. Choi, W.-C. Kim, S.-H. Lee, N.-C. Park, and U. Y.-P. Park, "Effects of fabrication errors in the diffractive optical element on the modulation transfer function of a hybrid lens," *Journal of the Optical Society of America A: Optics and Image Science, and Vision*, vol. 25, no. 11, pp. 2764–2766, 2008.
2. Zemax Product, <http://www.zemax.com>.
3. G. J. Swanson, *Binary Optics Technology*, Massachusetts Institute of Technology, Cambridge, Mass, USA, 1989.
4. A. D. Kathman and S. K. Pitalo, "Binary optics in lens design," in *International Lens Design Conference*, vol. 1354 of *Proceedings of SPIE*, 1990.
5. Lambda Research Corporation, OSLO, version 6.2, 2001.
6. N.-H. Kim and R. Zemax, "How Diffractive Surfaces are Modeled in Zemax," September 2005.
7. Code V reference manual, CODE V version 7.10, Optical Research Associates, March 1987.
8. T. Shirakawa, K. L. Ishikawa, S. Suzuki, Y. Yamada, and H. Takahashi, "Design of binary diffractive microlenses with subwavelength structures using the genetic algorithm," *Optics Express*, vol. 18, no. 8, pp. 8388–8391, 2010.
9. V. Raulot, B. Serio, P. Gerard, P. Twardowski, and P. Meyrueis, "Modeling of a diffractive micro-lens by an effective medium method," in *Micro-Optics 2010*, 77162J, vol. 7716 of *Proceedings of SPIE*, May 2010.
10. E. N. Glytsis, M. E. Harrigan, T. K. Gaylord, and K. Hirayama, "Effects of fabrication errors on the performance of cylindrical diffractive lenses: rigorous boundary-element method and scalar approximation," *Applied Optics*, vol. 37, no. 28, pp. 6591–6602, 1998.
11. J. Jahns and S. J. Walker, "Two-dimensional array of diffractive microlenses fabricated by thin film deposition," *Applied Optics*, vol. 29, no. 7, pp. 931–936, 1990.
12. M. Alshami, A. Wabby, and M. F. Mousselly, "Design and development of binary diffractive Germanium lens by thin film deposition," *Journal of the European Optical Society*, vol. 10, Article ID 15055, 2015.
13. D. A. Pommet, E. B. Grann, and M. G. Moharam, "Effects of process errors on the diffraction characteristics of binary dielectric gratings," *Applied Optics*, vol. 34, no. 14, pp. 2430–2435, 1995. [14] T. G. Jabbour, *Design, Analysis, and Optimization of Diffractive Optical Elements under High Numerical Aperture Focusing*, University of Central Florida, 2009.
15. G. J. Swanson and W. B. Veldkamp, "Diffractive optical elements for use in infrared systems," *Optical Engineering*, vol. 28, no. 6, pp. 605–608, 1989.

Commented [A28]: Per instructions, the references have been excluded from the edit. Please ensure that these citations are accurate and formatted according to the requirements of your target journal.